fs Industrial Femtosecond Lasers

FemtoLux 30

Reliability Redefined

A reliable & versatile tool for micromachining

/ Glass, sapphire and ceramics micro processing

/ Microelectronics manufacturing

/ Glass intra volume structuring

/ Micro processing of different polymers and metals

/ LCD, LED, OLED drilling, cutting and repair

Zero maintenance

2 years of total warranty

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30 W Femtosecond Industrial Laser

FemtoLux 30

Designed from the get-go for maximum reliability, seamless integration and non-stop 24/7/365 zero maintenance operation with innovative "dry" cooling.

The FemtoLux 30 femtosecond laser has a tunable pulse duration from <350 fs to 1 ps and can operate in a broad AOM controlled range of pulse repetition rates from a single shot to 4 MHz.

The maximum pulse energy is more than 90 µJ operating with single pulses and can reach 250 µJ in burst mode, ensuring higher ablation rates and processing throughput for different materials.

The FemtoLux 30 beam parameters will meet the requirements of the most demanding materials and micro-machining applications.

Innovative laser control electronics ensure simple control of the FemtoLux 30 laser by external controllers that could run on different platforms, be it Windows, Linux or others using REST API commands.

This makes easy integration and reduces the time and human resources required to integrate this laser into any laser micromachining equipment.

Seamless User Experience

Easy integration – remote control using REST API via RS232 and LAN.

Reduced integration time – demo electronics is available for laser control programming in advance.

Easy and quick installation – no water, fully disconnectable laser head. Can be installed by the end-user.

Easy troubleshooting – integrated detectors and constant system status logging.

No periodic maintenance required.

Features

Typical max output power
30 W at 1030 nm,
11 W at 515 nm

> 90 µJ at 1030 nm,
> 50 µJ at 515 nm

MHz, GHz burst modes

> 250 µJ in a burst mode

< 350 fs – 1 ps

Single shot to 4 MHz
(AOM controlled)

<0.5% RMS power long term stability over 100 hours

M^2 < 1.2

Beam circularity > 0.85

Zero maintenance

Dry cooling (no water used)

PSU and cooling unit integrated into single 4U rack housing

Easy and quick installation

Compatible with galvo and Polygon scanners as well as PSO controllers

2 years of total warranty

At 1030 nm	At 515 nm	Single shot (AOM)
30 W	11 W	up to 4 MHz
>90 µJ	>50 µJ	350 fs – 1 ps

Learn more
about FemtoLux 30
www.ekspla.com

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"Dry" Cooling

Direct Refrigerant Cooling System

The FemtoLux 30 laser employs an innovative cooling system and sets new reliability standards among industrial femtosecond lasers. No additional bulky and heavy water chiller is needed.

The chiller requires periodic maintenance – cooling system draining and rinsing and water and particle filter replacement. Moreover, water leakage can cause damage to the laser head and other equipment. Instead of using water for transferring heat from a laser head, the FemtoLux 30 laser uses an innovative Direct Refrigerant Cooling method.

The refrigerant agent circulates from a PSU-integrated compressor and condenser, to a cooling plate via armored flexible lines.

The entire cooling circuit is permanently hermetically sealed and requires no maintenance.

See **FemtoLux 30** introduction video showing "dry cooling" advantages

Benefits

Military-grade reliability

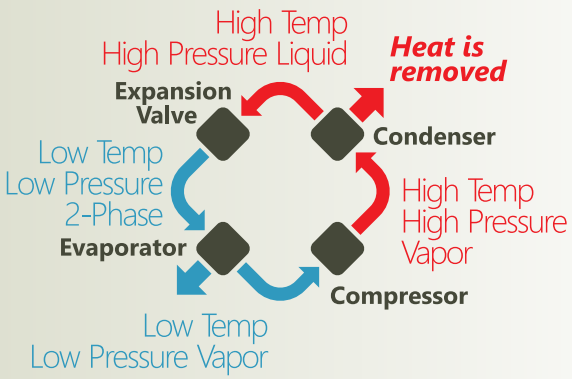
Permanently hermetically sealed system **>90,000 hour MTBF**

No maintenance

High cooling efficiency

>45% lower power consumption compared to water cooling equipment

Compact and light



Compressor picture.
Courtesy of Aspen Systems Inc.

Simple & Reliable Cooling Plate Attachment

The cooling plate is detachable from the laser head for more convenient laser installation. The laser cooling equipment is integrated with the laser power supply unit into a single 4U rack-mounted housing with a total weight of 15 kg.

Detachable cooling plate

Integrated cooling equipment with the laser power supply

Simple and reliable cooling plate attachment

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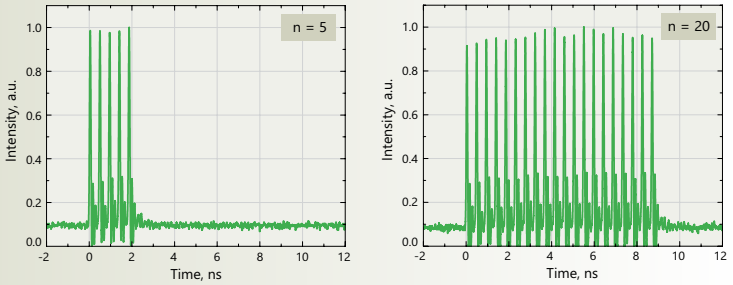
GHz Burst Option

Patent-Pending Method for Ultra-High Rate Bursts

Short GHz burst

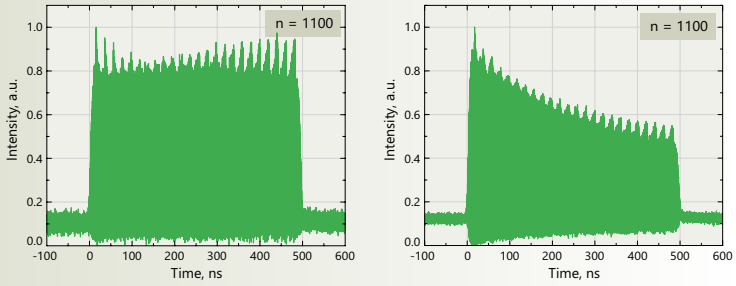
Fig 12. Measured 2.2 GHz intra-burst PRR burst of pulses containing a different number of pulses of equal amplitudes at 31.5 W average output power



Long GHz burst

Fig 13. Measured 2.2 GHz pre-shaped bursts of 1000 pulses at 233 kHz burst repetition rate for the desired rectangular-like burst shape

Fig 14. Measured 2.2 GHz non-pre-shaped bursts of 1100 pulses at 233 kHz burst repetition rate



A new versatile patent-pending method to form ultra-high repetition rate bursts of ultrashort laser pulses.

The developed method is based on the use of an all-in-fiber active fiber loop (AFL). A detailed description of the invention can be found on:

[1] Andrejus Michailovas, and Tadas Bartulevičius. 2021 Int. patent application published under the Patent Cooperation Treaty (PCT) WO2021059003A1.

[2] Tadas Bartulevičius, Mykolas Lipnickas, Virginija Petrauskienė, Karolis Madeikis, and Andrejus Michailovas, (2022), "30 W-average-power femtosecond NIR laser operating in a flexible GHz-burst-regime," Opt. Express 30, 36849-36862.

Specifications

Parameter	Value	
Burst repetition rate	200 – 650 kHz	
Intra-burst pulse repetition rate [1]	2 GHz	
GHz burst mode	**short**	**long**
Number of pulses [2]	2 – 22	44 – 1100
Shape	square, rising, falling	falling, pre-shaped [3]

[1] Custom intra-pulse PRR is available upon a request.
[2] Depends on the intra-pulse PRR.
[3] For more information, please inquire sales@ekspla.com.

Benefits

The Femtolux 30 laser can operate in the **single-pulse** mode, **MHz burst** mode and **GHz burst** mode.

The burst formation technique based on the use of the AFL is a very versatile method as it allows to overcome many limitations encountered by other fiber- and/or solid-state-based techniques.

The benefits of this technology:

Any desired intra-burst PRR can be achieved independently from the initial PRR of the master oscillator

Identical pulse separation inside the GHz bursts is maintained

Short- and long-burst formation modes can be provided.

/ A short burst is up to about 10 ns burst width (from 2 to tens of pulses in the GHz burst).

/ A long burst is from ~20 ns up to a few hundred ns in burst width (from tens to thousands of pulses in the GHz burst)

An adjustable amplitude envelope of the GHz bursts is provided

No pre/post pulses in GHz burst. Pure GHz bursts

Ultrashort pulse duration is maintained inside the bursts

See video showing principle of **AFL technology**

Specifications [1)]

Model		FemtoLux 30
Main specifications		
Central wavelength	fundamental	1030 nm
	with second harmonic option	515 nm
Pulse repetition rate (PRR) [2)]		200 kHz – 4 MHz
Pulse repetition frequency (PRF) after frequency divider		PRF = PRR / N, N=1, 2, 3, … , 65000; single shot
Average output power	at 1030 nm	> 27 W (typical 30 W)
	at 515 nm	> 11 W [3)]
Pulse energy	at 1030 nm	> 90 µJ
	at 515 nm	> 50 µJ [3)]
Total energy in MHz/GHz burst mode		> 250 µJ
Power long term stability (Std. dev.) [4)]		< 0.5 %
Pulse energy stability (Std. dev.) [5)]		< 1 %
Pulse duration (FWHM)		tunable, < 350 fs [6)] – 1 ps
Beam quality		M^2 < 1.2 (typical < 1.1)
Beam circularity, far field		> 0.85
Beam divergence (full angle)		< 1 mrad
Beam pointing thermal stability		< 20 µrad/°C
Beam diameter ($1/e^2$) at 20 cm distance from laser aperture at 1030 nm		2.5 ± 0.4 mm
Triggering mode		internal / external
Pulse output control		frequency divider, pulse picker, burst mode, packet triggering, power attenuation
Control interfaces		RS232 / LAN
Length of the umbilical cord		3 m, detachable
Laser head cooling type		dry (direct refrigerant cooling through detachable cooling plate)
Physical characteristics		
Laser head (W × L × H)		429 × 569 × 130 mm
Power supply unit (W × L × H)		449 × 376 × 177 mm
Operating requirements		
Mains requirements		100 – 240 V AC, single phase, 50/60 Hz
Operating ambient temperature		18 – 27 °C
Relative humidity		10–80 % (non-condensing)
Air contamination level		ISO 9 (room air) or better

1) Due to continuous improvement, all specifications are subject to change without notice. Parameters marked typical are not specifications. They are indications of typical performance and will vary with each unit we manufacture. All parameters are specified for a shortest pulse duration.

2) When frequency divider is set to transmit every pulse. Fully controllable by integrated AOM.

3) At 200 kHz.

4) Over 100 h after warm-up under constant environmental conditions.

5) Under constant environmental conditions.

6) At PRR > 500 kHz. At PRR < 500 kHz shortest pulse duration is < 400 fs.

DANGER: VISIBLE AND/OR INVISIBLE LASER RADIATION AVOID EYE OR SKIN EXPOSURE TO DIRECT, REFLECTED OR SCATTERED RADIATION
CLASS 4 LASER PRODUCT

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Performance

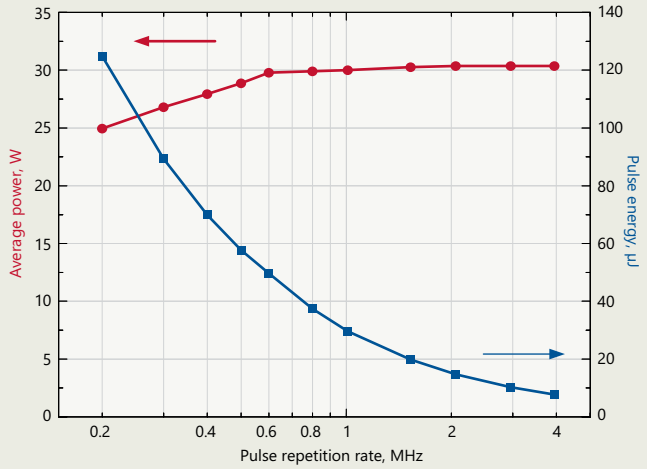

Fig 1. Typical dependence of output power and pulse energy of FemtoLux 30 laser at 1030 nm on pulse repetition rate

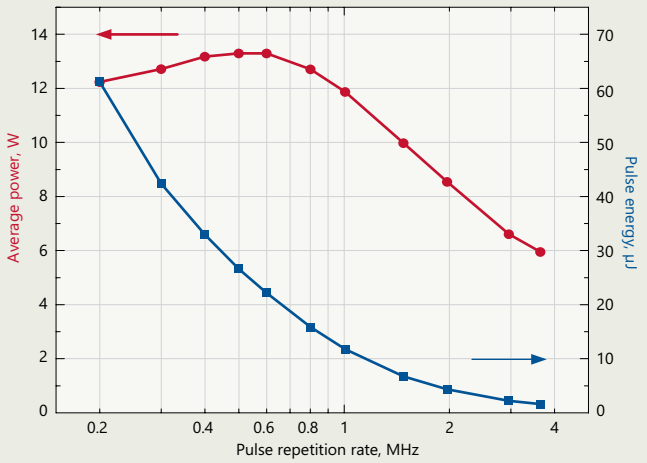

Fig 2. Typical dependence of output power and pulse energy of FemtoLux 30 laser at 515 nm on pulse repetition rate

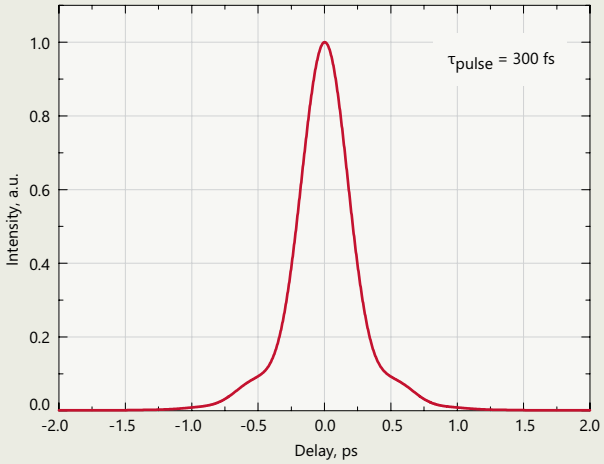

Fig 3. Typical FemtoLux 30 laser (at 1030 nm) output pulse autocorrelation function

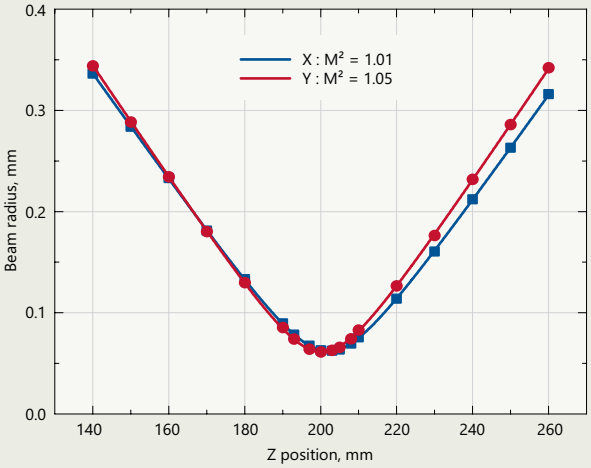

Fig 4. Typical M^2 measurement of FemtoLux 30 laser at 1030 nm

FemtoLux 30 with second harmonic option and power supply

Stability

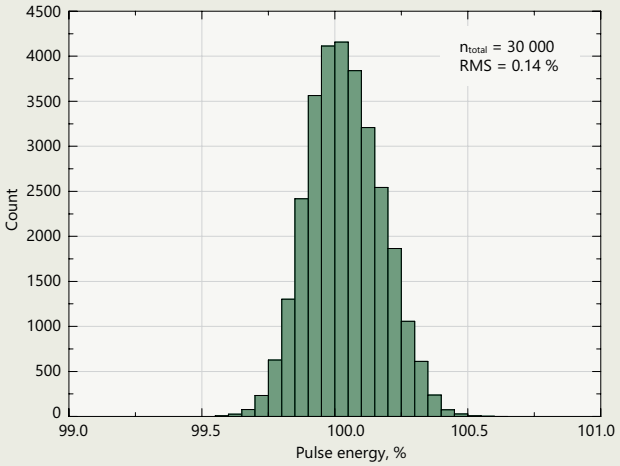

Fig 5. Typical pulse-to-pulse energy stability of FemtoLux 30 laser at 200 kHz over 30 000 pulses. RMS was calculated by using a set of mean values of 10 consecutive laser shots

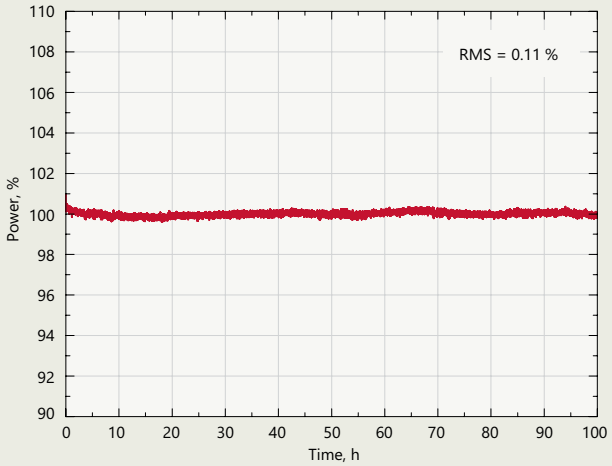

Fig 6. Typical long term average power stability of FemtoLux 30 laser at 1030 nm under constant environmental conditions

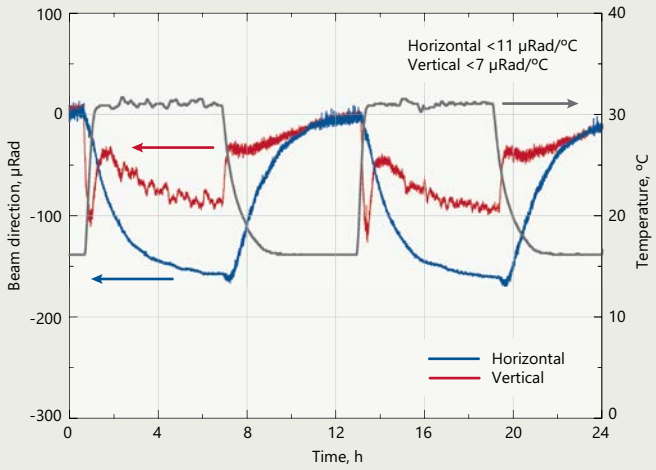

Fig 7. Typical beam direction stability of FemtoLux 30 under harsh environmental conditions

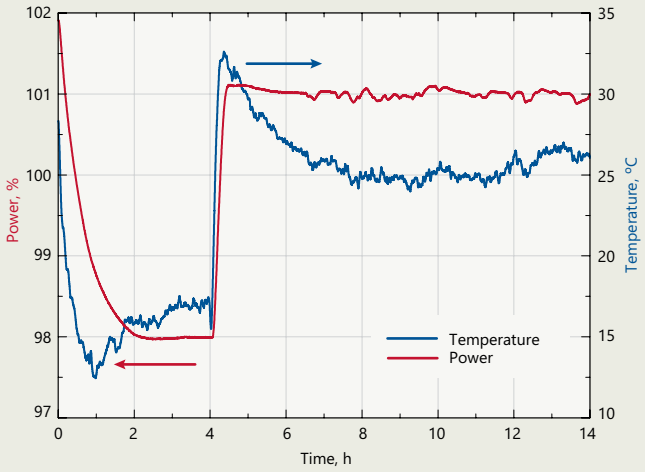

Fig 8. Average output power dependance of FemtoLux 30 laser on ambient temperature at 1030 nm

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Drawings

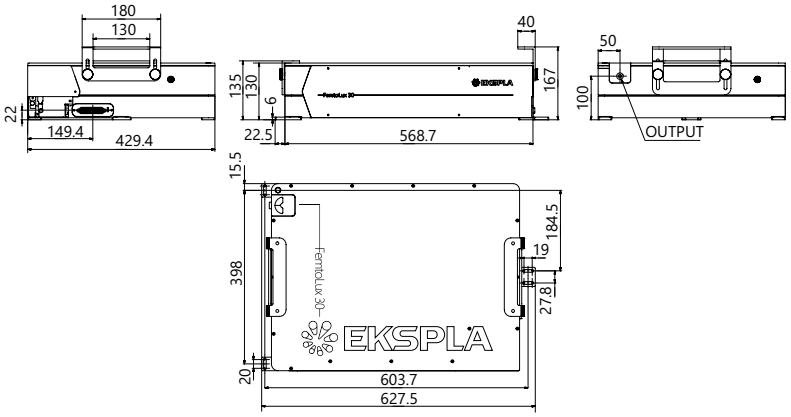

Fig 9. FemtoLux 30 laser head outline drawing

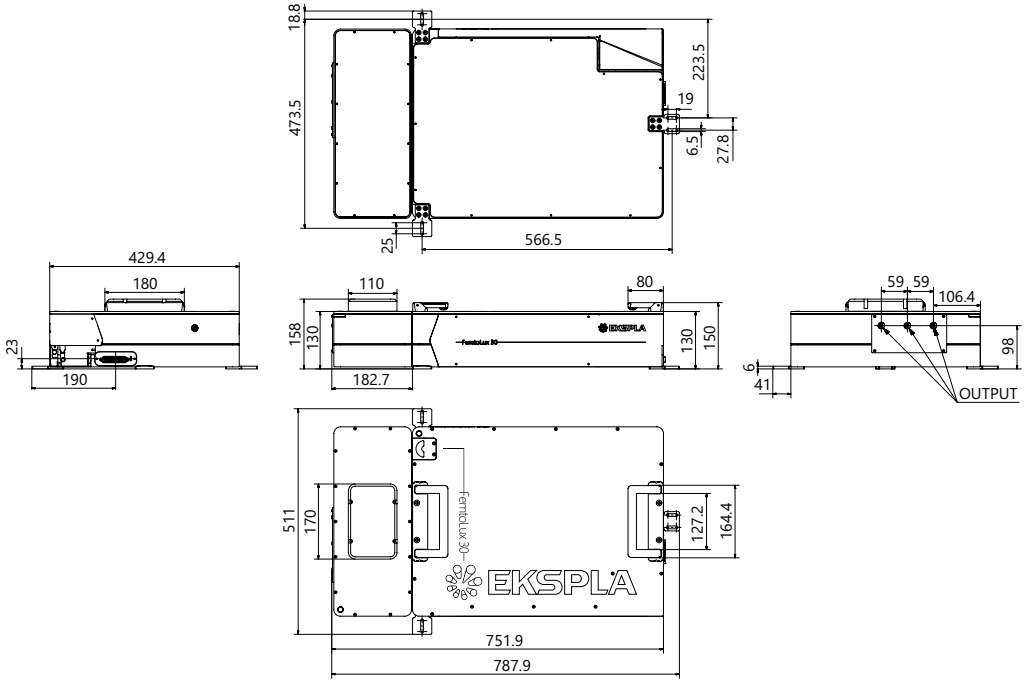

Fig 10. FemtoLux 30 with second harmonic option. Laser head outline drawing

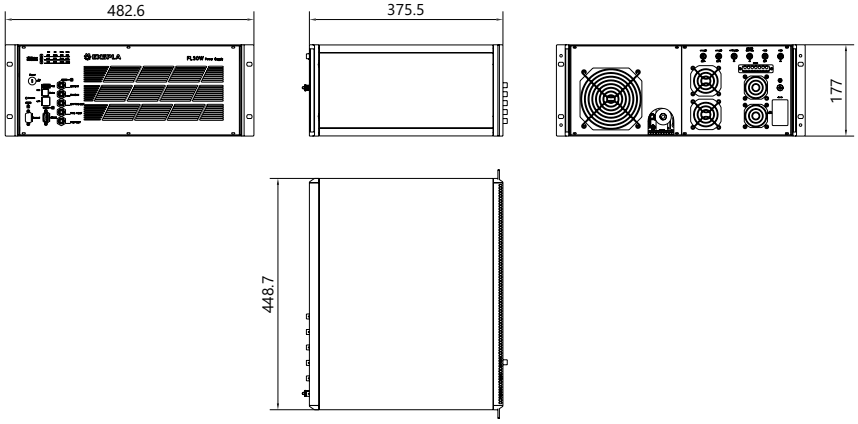

Fig 11. Power supply outline drawing